



ITW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 3102**
Satoshi TANAKA et al. : Attorney Docket No. 2005_0626A
Serial No. 10/531,006 : Group Art Unit 4111
Filed April 12, 2005 : Examiner Robert J. Grun

FOAM MOLDING METHOD AND APPARATUS

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Restriction Requirement of April 17, 2008, Applicants hereby elect Group I, which is drawn to a foam molding method and apparatus requiring a pressurized mold cavity to control foaming of the molding material and is embodied by claims 1-27.

Having made the required election, a full examination on the merits of the elected group is requested.

Respectfully submitted,

Satoshi TANAKA et al.

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TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO. 23-0975